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TS01-167CB

March 3, 2004

To: Mail Stop: Application Number  
Commissioner For Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

From: Stephen B. Ackerman

Subject: Serial No.: 10/696,432  
Filing Date: 10/29/03  
Inventor: Y. L. Wang, et al  
Title: CMP Process Leaving no Residual Oxide Layer of Slurry  
Particles

### REQUEST TO CORRECT FILING RECEIPT

Dear Sir:

On the copy of the enclosed Filing Receipt, there is an error in the list of Applicants. The sixth Applicant's residence is misspelled. Mr. Cheng's name and corrected residence reads; **Wen-Kung Cheng, Toufen City, Taiwan.**

Please make the necessary change to correct the error on the Filing Receipt.

If there are any questions, please contact the undersigned attorney at (845) 452-5863. Thank you for your attention to this matter.

Respectfully Submitted,

Stephen B. Ackerman, Reg. No, 37,761

FEB. 04 2004



## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/696,432	10/29/2003	1742	770	TS01-167CB	3	10	2

George O. Saile  
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CONFIRMATION NO. 6825

## FILING RECEIPT



\*OC000000011796221\*

Date Mailed: 01/30/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

Ying-Lang Wang, Tien-Chung Village, TAIWAN;  
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*Taiwanese*

## Assignment For Published Patent Application

TAIWAN SEMICONDUCTOR MANUFACTURING COMPANY;

## Domestic Priority data as claimed by applicant

This application is a DIV of 10/038,389 01/03/2002 PAT 6,660,638

## Foreign Applications

If Required, Foreign Filing License Granted: 01/29/2004

Projected Publication Date: 05/06/2004

Non-Publication Request: No

Early Publication Request: No

**Title**

CMP process leaving no residual oxide layer or slurry particles

**Preliminary Class**

205

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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